	Application No.	Applicant(s)
	09/771,673	SPREY ET AL.
Notice of Allowability	Examiner	Art Unit
	Sylvia R MacArthur	1763
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. 🗵 This communication is responsive to <u>the amendment sent</u> .		
2. ⊠ The allowed claim(s) is/are <u>15-33</u> .		
3. 🔀 The drawings filed on 29 January 2001 are accepted by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: Certified copies of the priority documents have Certified copies of the priority documents have Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM 	e been received. e been received in Application No cuments have been received in this i	national stage application from the
THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF		
INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
 6. CORRECTED DRAWINGS (as "replacement sheets") mus (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the 	on's Patent Drawing Review (PTO-S s Amendment / Comment or in the O .84(c)) should be written on the drawin	office action of
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/0	6. ⊠ Interview Summary (Paper No./Mail Date	
Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	9.	nt of Reasons for Allowance
	S	UPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700

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EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Adeel Akhtar and Zi Wong on July 22, 2004.

2. The application has been amended as follows:

In claim 15, line 19 "walls of" were added before the first occurrence of - - auxiliary - - and "walls of" were added before - piping—

Claim 28, now reads:

28. A system for etching a substrate, comprising:

an etching chamber for the substrate;

a piping system in fluid communication with the etching chamber and having at least a first fluid feed and a second fluid feed, wherein the first fluid feed is connected at a source end to a source of a first etching gas, wherein the second fluid feed is connected at a source end to a source of a second etching gas;

an auxiliary chamber positioned within the piping system and having an inlet and an outlet, wherein the inlet includes a first controllable shut-off valve and is in gas communication

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with the first fluid feed and the outlet includes a second controllable shut- off valve and is in gas communication with the etching chamber;

a third controllable shut-off valve positioned in the piping system in the second fluid feed;

means for preventing diffusion of the second etching gas through the inlet of the auxiliary chamber by opening the first and second shut-off valves only one at a time and by opening the second and the third shut-off valves only one at a time: and

wherein the walls of the auxiliary chamber and the piping system upstream of the auxiliary chamber are each formed of different materials.

3. The following is an examiner's statement of reasons for allowance:

The prior art of record fails to teach or fairly suggest a system of etching a substrate wherein the walls of the auxiliary chamber and the piping system upstream of the auxiliary chamber are each formed of different materials.

4. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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5. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Sylvia R MacArthur whose telephone number is 571-272-1438.

The examiner can normally be reached on M-F during the core hours of 8 a.m. and 2 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Gregory L. Mills can be reached on 703-308-1633. The fax phone number for the

organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SMvia R MacArth Patent Examiner Art Unit 1763

July 23, 2004

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